A micromachined pressure/flow-sensor


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Abstract

The micromechanical equivalent of a differential pressure flow-sensor, well known in macro mechanics, is discussed. Two separate pressure sensors are used for the device, enabling to measure both, pressure as well as volume flow-rate. An integrated sensor with capacitive read-out as well as a hybrid, piezo-resistive variant is made. The fabrication processes are described, using silicon and glass processing techniques. Based on the sensor layout, equations are derived to describe the sensor behavior both statically as well as dynamically. With the derived equations, the working range of the sensor and the thermal and time stability is estimated. The computed results of the stationary behavior are verified with the measured data. A good similarity in linearity of the pressure flow relation is found. The computed hydraulic resistance, however, differs from the measured value for water with 21%. This difference can be explained by the high sensitivity of the resistance to the resistor channel cross-section parameter in combination with the difference between the rounded etched shape and the rectangular approximation. From fluid dynamics simulations, a working range bandwidth of about 1 kHz is expected. Thermal influences on the sensor signal due to viscosity changes are in the order of 2% flow signal variation per Kelvin. From these results, it can be concluded that the sensor can be used as a low cost, low power consuming flow and pressure-sensing device, for clean fluids without particles and without the tendency to coat the channel walls. If a high accuracy is wanted, an accurate temperature sensing or controlling system is needed. © 1999 Elsevier Science S.A. All rights reserved.

Keywords: Flow-sensors; Pressure-sensors; Modeling

1. Introduction

In the area of integrated fluid analysis systems such as µ-TAS (micro total analysis system), liquid or gas flows need to be measured and controlled [1–3]. The flows can be dosed by using, for instance, regulated micro pumps and active valves [4–6]. To adapt the flow delivery to changing impedances and to know exactly the parameters, at which it is delivered, sensors are needed. The parameter of interest for feeding the chemical detection system is mass flow. Pressure is the complementary parameter, needed to compute the applied hydraulic power. In this paper is discussed the pressure/flow-sensor, which can sense both parameters and therefore deliver all relevant information for flow and pressure delivery in a µ-TAS. The pressure is measured with capacitive or piezo-resistive pressure sensors, whereas the flow rate is computed from the pressure drop over a well defined, hydraulic resistance.

2. The flow sensing principle

The flow sensing principle of the pressure/flow-sensor is to measure the pressure drop over a hydraulic resistor. Deriving the flow-rate out of this differential pressure signal is well known. There are two ways to obtain a relation. A conversion of kinetic energy (speed) to potential energy (pressure) can be accomplished by leading the flow through a converging/diverging nozzle such that the speed is increased locally. Measuring the dynamic and static pressure and using the relation between pressure and velocity according to Bernoulli gives the fluid speed [7]. This principle is used in venturi type macro flow-sensors and is only applicable when no substantial energy losses due to friction are expected. For micro channels with liquid flows at low Reynolds values, this energy loss cannot be neglected. Therefore, we chose for measuring...
the pressure loss over a hydraulic resistance [8]. This means that the sensor is passive and a small amount of hydraulic energy is extracted from the fluid flow and transformed into a pressure drop signal. The principle is similar to the well-known use of an electrical shunt resistor to convert current into a measurable voltage drop.

3. Fabrication

The functional layout of the sensor is drawn in Fig. 1. To guarantee that the static pressure instead of the dynamic pressure is measured, the fluid velocity in the resistor must be much higher than at the points where pressure is measured. Therefore, two chambers, one at the entrance and one at the exit, are needed. The space required for the pressure sensor membranes can be used for this.

For the micro pressure/flow-sensor, we made two prototypes, one hybrid design, consisting of two piezo-resistive sensor dies, glued on top of a 10 × 5 × 0.9 mm glass–silicon substrate, embedding the resistor channel and a fully, 10 × 5 × 1.4 mm integrated design with capacitive pressure sensors. Fig. 2 shows a schematic view of the hybrid variant. With an-isotropic KOH etching, holes were made through <(100) oriented silicon. After the resistor channels are isotropically etched in the glass wafer with HF, using chromium as a mask layer, holes are created through the wafer, using a powder blasting process. With the use of the anodic bonding process, the glass wafer is mounted on the silicon wafer. A stamping method is used to pattern glue accurately on the pressure-sensor dies (∼100 μm precision), after which the dies are mounted on top of the glass–silicon sandwich. Finally, the dies are mounted on a ‘system board’ and electrical and fluidic connections are made (Fig. 3).

Since the sensor principle is passive and needs no actuation power, a low power version is designed by replacing the piezo-resistive pressure sensors by capacitive transducers. For this, a fully integrated design has been made. Figs. 1 and 4 show the cross-sections. The sensor is built in a glass–silicon–glass sandwich structure. In the bottom glass wafer, the hydraulic resistors are etched, again using isotropic HF etching in combination with a chromium mask (Fig. 5, sequence C). After this, holes through the glass are created.

The top wafer holds the upper, fixed electrodes for reading-out the membrane deformations as a function of the applied pressure. By depositing the electrodes in a cavity, the initial gap between the electrodes is defined. The process steps used for this are drawn in Fig. 5.
sequence A. The first step (A1) consists of patterning a chromium mask layer by means of a wet chromium etching technique. After the glass is etched in HF such that the cavities have reached the required depth (A2), chromium and platinum are deposited (A3). Since the resist--chromium mask is under etched during the HF step, the mask is used as a shadow mask as well, such that the edges of the top electrode are well defined inside of the cavity. With this combined etch and shadow mask, the electrode material is only deposited at the bottom such that short-circuiting of the electrical connections is avoided. After stripping the resist/chromium layers in HNO₃, the glass wafer with the top electrodes is finished.

The silicon wafer contains the membranes and complementary electrodes for the pressure sensors. First, the membranes are etched anisotropically in a KOH solution, using silicon nitride as mask and defining the membrane thickness by a stop in time (steps B1–2). After this, the silicon nitride at the membrane side is removed at areas that need to be bonded and the lower electrodes are patterned with a lift-off technique.

For bonding the two glass wafers with the silicon wafer, the anodic bonding method is used. Because the distance between the upper and lower electrodes is rather small, the electrostatic forces on the membranes during the bonding process could damage the sensor. Therefore, all upper and lower electrodes are connected to the same potential, resulting in a potential drop between the glass and silicon only. Dicing of the sensors is done such that the connections to the upper and lower electrodes become accessible. For this, a V-groove is etched in the silicon and the top and bottom glass wafers are partly diced at a shifted...
After breaking, the bond pads become accessible, as shown in Fig. 6.

### 4. Modeling of the stationary sensor behavior

#### 4.1. Pressure-sensor membranes

Varying the resistors and/or the dimensions of the sensor membranes makes it possible to adapt the sensor for a specific flow and pressure range. To predict the effects of the different design parameters, we derived simple design formulas for the fluid mechanical and structural mechanical behavior. Only the fully integrated capacitive pressure/flow-sensor will be discussed, since commercially available pressure sensor dies were used for the piezo-resistive variant.

The used parameters are summarized in Table 1. The capacitance/pressure relation of the sensors is defined by, among others, the stiffness of the membranes. For small deflections the dimensionless linear pressure/deflection membrane formula (1) can be used [9,10]:

\[
Q = K_q W_0
\]

The parameter definitions are given in Table 2. \( Q \) is a dimensionless load parameter, \( K_q \) the bending stiffness and \( W_0 \) the center deflection of the membrane relative to the membrane thickness. Relation (1) fits well for deflections \( W_0 \), smaller than about 0.5. For values of \( W_0 \) larger than 0.5, the in-plane stresses become important resulting in a non-linear load deflection relation. A simple approximation for these situations with additional pre-stress is given by:

\[
Q = K_q W_0 + K_d W_0^3
\]

In this relation, \( K_q \) is the pre-stress term whereas \( K_d \) represents the net stiffness constant when in-plane stresses become important. For circular and square membranes, the definitions of the stiffness constants differ. Analytical and numerical results have been presented in literature [9,10].

To compute the electric and hydraulic capacitance of the pressure sensor, the deflection shape of the membrane is needed. For round membranes, the spherical relation is given by:

\[
W = W_0 (1 - R^2)^2
\]

For square membranes, the deflection as well as the clamped edges are described by the spherical relation:

\[
W = W_0 (1 - X^2)^2 (1 - Y^2)^2
\]

#### 4.2. Electric pressure-sensor capacitance

The electric capacitance of the pressure sensor varies when pressure is applied on the membranes due to the changing gap geometry between the upper and lower

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Table 1
Dimensional parameters and units used for the membrane theory and capacitance calculation

<table>
<thead>
<tr>
<th>Membrane theory</th>
<th>Parameter or constant</th>
<th>Units</th>
<th>Capacitance</th>
<th>Parameter or constant</th>
<th>Units</th>
</tr>
</thead>
<tbody>
<tr>
<td>Pressure</td>
<td>( p )</td>
<td>N/m²</td>
<td></td>
<td>( \varepsilon )</td>
<td>( \text{c}^2/\text{Nm} )</td>
</tr>
<tr>
<td>Deflection</td>
<td>( w )</td>
<td>m</td>
<td></td>
<td>( \varepsilon_r )</td>
<td>( \text{c}^2/\text{Nm}^2 )</td>
</tr>
<tr>
<td>Center deflection</td>
<td>( w_0 )</td>
<td>m</td>
<td></td>
<td>( \varepsilon_r )</td>
<td>–</td>
</tr>
<tr>
<td>Thickness</td>
<td>( h )</td>
<td>m</td>
<td></td>
<td>( s )</td>
<td>m²</td>
</tr>
<tr>
<td>Radius</td>
<td>( a )</td>
<td>m</td>
<td>Gap distance</td>
<td>( d_0 )</td>
<td>m</td>
</tr>
<tr>
<td>Length</td>
<td>( 2a )</td>
<td>m</td>
<td>Gap distance (unloaded)</td>
<td>( d_0 )</td>
<td>m</td>
</tr>
<tr>
<td>Radius coordinate.</td>
<td>( r )</td>
<td>m</td>
<td>Inner electrode radius</td>
<td>( r_{e1} )</td>
<td>m</td>
</tr>
<tr>
<td>Angular coordinate.</td>
<td>( \theta )</td>
<td>rad</td>
<td>Outer electrode radius</td>
<td>( r_{e2} )</td>
<td>m</td>
</tr>
<tr>
<td>( x-y ) coordinates</td>
<td>( x, y )</td>
<td>m</td>
<td>Outer ( x )-coordinate electrode</td>
<td>( x )</td>
<td>m</td>
</tr>
<tr>
<td>Modulus of elasticity</td>
<td>( E )</td>
<td>N/m²</td>
<td>Outer ( y )-coordinate electrode</td>
<td>( y )</td>
<td>m</td>
</tr>
<tr>
<td>Poisson’s constant</td>
<td>( \nu )</td>
<td>–</td>
<td>Electrode area</td>
<td>( S_e )</td>
<td>m²</td>
</tr>
<tr>
<td>Pre-stress</td>
<td>( \sigma_0 )</td>
<td>N/m²</td>
<td></td>
<td>( )</td>
<td>( )</td>
</tr>
</tbody>
</table>

Table 2
Definition of the introduced dimensionless membrane and capacitance parameters

<table>
<thead>
<tr>
<th>Membrane theory</th>
<th>Parameter</th>
<th>Elements</th>
<th>Capacitance</th>
<th>Parameter</th>
<th>Elements</th>
</tr>
</thead>
<tbody>
<tr>
<td>Load</td>
<td>( Q )</td>
<td>( pa^4/Eh^4 )</td>
<td>Specific capacitance</td>
<td>( C )</td>
<td>( ch/\varepsilon a^2 )</td>
</tr>
<tr>
<td>Deflection</td>
<td>( W )</td>
<td>( w/h )</td>
<td>Gap distance (unloaded)</td>
<td>( D_0 )</td>
<td>( d_0/h )</td>
</tr>
<tr>
<td>Center deflection</td>
<td>( W_0 )</td>
<td>( w_0/h )</td>
<td>Inner electrode radius</td>
<td>( R_{e1} )</td>
<td>( r_{e1}/a )</td>
</tr>
<tr>
<td>Radius coordinate.</td>
<td>( R )</td>
<td>( r/a )</td>
<td>Outer electrode radius</td>
<td>( R_{e2} )</td>
<td>( r_{e2}/a )</td>
</tr>
<tr>
<td>Angular coordinates.</td>
<td>( \theta )</td>
<td>( \theta )</td>
<td>Outer electrode ( x )-coordinate</td>
<td>( X_e )</td>
<td>( x/a )</td>
</tr>
<tr>
<td>( x-y ) coordinates</td>
<td>( X, Y )</td>
<td>( x/a, y/a )</td>
<td>Outer electrode ( y )-coordinate</td>
<td>( Y_e )</td>
<td>( y/a )</td>
</tr>
</tbody>
</table>
electrode. This pressure/capacitance relation can be approximated by the surface integral given in Eq. (5).

\[
c = \int_{S_c} \frac{e_0 \varepsilon_r}{d} dS = e_0 \varepsilon_r \int_{S_c} \frac{1}{d} dS
\]  

(5)

With \( d \) the gap distance between the upper and lower electrodes as a function of the position and the electrode area. Substitution of the shape function of a round membrane results in the dimensionless deflection/capacitance relation (6), where the circular electrode ranges from \( R = R_{e1} \) to \( R_{e2} \).

\[
c = \int_{R_{e1}}^{R_{e2}} 2\pi \left[ \frac{R}{D_0 - W_0 (1 - R^2)} \right] dR d\theta

= \pi \left[ \frac{W_0}{D_0} (R_{e2}^2 - 1) \right] - \pi \left[ \frac{W_0}{D_0} (R_{e1}^2 - 1) \right]
\]  

(6)

The center deflection, \( W_0 \), can be replaced by one of the Eq. (1) or Eq. (2), depending on the existence of large deformations and pre-stresses. For the square membranes, no analytical solutions exist so that the integrals must be computed numerically.

4.3. The hydraulic resistance

A pressure drop, related to the flow-rate, is obtained by energy dissipation in the resistance channel between the two pressure sensors. In our design, this is simply implemented by a narrowing of the channel cross-section. The pressure drop over a channel with an effective diameter, \( d_{eff} \), is given by Eq. (7) [11,12]. The used parameters are described in Table 3.

\[
\Delta p = f \frac{\rho v_{eff}^2}{2d_{eff}} l
\]  

(7)

In our applications, we assumed a rectangular shape of the resistor cross-section. The correction factor for this geometry [12] results in:

\[
\Delta p = \frac{1}{8} \left( \frac{\rho v_{eff}^2}{Re} \left( \frac{k_{th} \rho}{S} \right) \right) l.
\]  

(8)

This equation shows the flow dependent and geometry dependent relation of the pressure drop. With the definition of the Reynolds number according to Eq. (9), and substituting this in the flow dependent part, Eq. (10) is obtained.

\[
Re = \frac{\rho v_{eff} d_{eff}}{\mu}
\]  

(9)

\[
\Delta p = \frac{1}{8} \left( \frac{\rho v_{eff}^2 d_{eff}}{\mu} \left( \frac{k_{th} \rho}{S} \right) \right) l
\]  

(10)

It is shown that the flow-sensor will measure the volume flow and is sensitive to viscosity changes. These aspects will be discussed further on in this article.

<table>
<thead>
<tr>
<th>Description</th>
<th>Dimensional parameter</th>
<th>Units</th>
</tr>
</thead>
<tbody>
<tr>
<td>Displaced volume</td>
<td>( V )</td>
<td>m³</td>
</tr>
<tr>
<td>Volume flow-rate</td>
<td>( \phi )</td>
<td>m³ s⁻¹</td>
</tr>
<tr>
<td>Kinematic viscosity</td>
<td>( \nu )</td>
<td>m² s⁻¹</td>
</tr>
<tr>
<td>Mass density</td>
<td>( \rho )</td>
<td>kg m⁻³</td>
</tr>
<tr>
<td>Wetted perimeter</td>
<td>( \phi )</td>
<td>m</td>
</tr>
<tr>
<td>Pressure drop</td>
<td>( \Delta p )</td>
<td>N m⁻²</td>
</tr>
<tr>
<td>Thermal expansion coefficient</td>
<td>( aT )</td>
<td>K⁻¹</td>
</tr>
<tr>
<td>Dynamic viscosity</td>
<td>( \mu )</td>
<td>N s m⁻²</td>
</tr>
<tr>
<td>Channel width</td>
<td>( a )</td>
<td>m</td>
</tr>
<tr>
<td>Channel depth</td>
<td>( b )</td>
<td>m</td>
</tr>
<tr>
<td>Hydraulic capacitance</td>
<td>( C_{hyd} )</td>
<td>N⁻¹ m⁵</td>
</tr>
<tr>
<td>Effective diameter</td>
<td>( d_{eff} )</td>
<td>m</td>
</tr>
<tr>
<td>Hydraulic diameter</td>
<td>( d_h )</td>
<td>m</td>
</tr>
<tr>
<td>Hydraulic power consumption</td>
<td>( E )</td>
<td>W</td>
</tr>
<tr>
<td>Friction factor</td>
<td>( f )</td>
<td>–</td>
</tr>
<tr>
<td>Resonance frequency</td>
<td>( f_{hyd} )</td>
<td>Hz</td>
</tr>
<tr>
<td>Hydraulic transfer function</td>
<td>( Q_{hyd} )</td>
<td>–</td>
</tr>
<tr>
<td>Temperature–viscosity constant</td>
<td>( k_{mu} )</td>
<td>–</td>
</tr>
<tr>
<td>Volume expansion coefficient</td>
<td>( k_p )</td>
<td>K⁻¹</td>
</tr>
<tr>
<td>Laminar friction constant</td>
<td>( k_{th} )</td>
<td>–</td>
</tr>
<tr>
<td>Minor loss coefficient</td>
<td>( k_m )</td>
<td>–</td>
</tr>
<tr>
<td>Specific heat capacity</td>
<td>( k_T )</td>
<td>J kg⁻¹ K⁻¹</td>
</tr>
<tr>
<td>Channel length</td>
<td>( l )</td>
<td>m</td>
</tr>
<tr>
<td>Hydraulic inertance</td>
<td>( L_{hyd} )</td>
<td>Ns² m⁻⁵</td>
</tr>
<tr>
<td>Quality factor</td>
<td>( Q_{hyd} )</td>
<td>–</td>
</tr>
<tr>
<td>Reynolds number</td>
<td>( Re )</td>
<td>–</td>
</tr>
<tr>
<td>Hydraulic resistance</td>
<td>( R_{hyd} )</td>
<td>Ns m⁻⁵</td>
</tr>
<tr>
<td>Cross-section area</td>
<td>( S )</td>
<td>m²</td>
</tr>
<tr>
<td>Time</td>
<td>( t )</td>
<td>s</td>
</tr>
<tr>
<td>Temperature</td>
<td>( T )</td>
<td>K</td>
</tr>
<tr>
<td>Effective velocity</td>
<td>( v_{eff} )</td>
<td>m s⁻¹</td>
</tr>
</tbody>
</table>

The HF etched channels in our sensor were relatively long and wide compared to the depth. In a first approximation we neglected the entrance and exit effects as well as the rounded corners, created during the isotropic etching process. The channel cross-section was assumed to be square. For this situation, the resistance can be described by Eq. (11). The parameters a and b are the side lengths of the cross-section. The friction constant can be obtained empirically and is found in literature [12]. Finally, the volume flow-rate can be extracted from the pressure drop with use of Eq. (12).

\[
R_{hyd} = \frac{\mu}{512} \left( \frac{k_{th}^2 (a + b)^2}{a^3 b^3} \right) l
\]  

(11)

\[
\phi = \frac{\Delta p}{R_{hyd}}
\]  

(12)

In this case, the measured pressure signal is linearly related to the flow-rate. The entrance and exit effects however cause so-called minor losses, which introduce a nonlinear behavior as is described by Eq. (13).

\[
\Delta p_{\text{minor}} = \frac{1}{2} \rho v_{eff}^2 k_m
\]  

(13)
For the situation of the resistance channel, the minor loss coefficient, $k_m$, can be as high as 0.5. The relative influence of the minor losses compared to the constant channel resistance is expressed in Eq. (14). This nonlinearity ratio represents the validity of neglecting the minor losses.

$$\frac{\Delta P_{\text{minor}}}{\Delta P_{\text{major}}} = \frac{256}{\nu} \frac{\phi}{k_m^2} \frac{ab}{(a + b)^2} l$$  (14)

For flow-rates on the order of a few microliters per second, a kinematic viscosity of about $10^{-6}$ m$^2$s$^{-1}$, an equal width and depth of the channel and a channel length of a few millimeters, the ratio will be less than 1%. Increasing the channel length can further reduce the non-linear effect of the minor losses. In Fig. 7, the measured and calculated pressure drop are shown as a function of the flow-rate in case water is used. As expected, the nonlinearity is very small and not noticeable. The difference between the measured and computed resistance is substantial (21%). The reason for this might be found in the cross-section geometry and roughness of the resistor channel. We assumed a smooth, rectangular geometry whereas pictures of the channel show a rounded trapezium shape. These rounded corners reduce the net effective cross-section area, which means an increase in resistance. Since the cross-section parameter influences the resistance to the power four as shown in Eq. (11), this substantial difference between the measurements and computed resistance can easily be obtained: a 21% resistance difference is caused by a net dimension difference of 4.8%.

If only major losses are taken into account, the hydraulic energy dissipation per unit time (power) is:

$$\dot{E}_{\text{hyd}} = \Delta P_{\text{major}} \phi = R_{\text{hyd}} \phi^2$$  (15)

This loss of hydraulic energy is converted to thermal energy and thus will rise the fluid temperature. Under the assumption that the heat is only transferred uniformly to the fluid without losses to the channel walls, this temperature rise is given by:

$$\Delta T = \frac{\phi R_{\text{hyd}}}{\rho \kappa_T}$$  (16)

For a sensor design, used in combination with ethanol, resulting in a hydraulic resistance of $1.7 \times 10^{12}$ Ns/m$^5$, with a density of 787 kg/m$^3$, heat capacity of $2.44 \times 10^3$ J/kg K and used to measure flows of 1 μl/s, the dissipated energy is 1.70 μW. Since this dissipated energy will heat up the liquid only $8.9 \times 10^{-4}$ K, the effect is negligible. It shows that the pressure/flow-sensor can be designed to consume besides electrical power, little hydraulic power as well.

5. Modeling of the dynamic sensor behavior

When the sensor is operated in a system with fast fluctuating fluid speeds, it is important to know the dynamics. An example of such application would be to sense the flow-rate produced by a membrane pump. The dynamic behavior of the sensor is important to predict the time dependent signal from the delivered flow and pressure. Due to the dynamic impedance of the sensor, a frequency dependent amplitude change and phase shift of the pressure signal, described by the transfer function, can occur. Transfer functions are based on the assumption of harmonic flows. In practice it is difficult to obtain this situation, but if a linear system is assumed, other, non-harmonic flows can be modeled by using Fourier series. A good indication about the dynamic behavior in the frequency domain can be obtained, which is used to estimate the working range of the sensor. Besides the computed hydraulic resistance of the channel, the sensor consists of
hydraulic capacities and inerance [13] also. In Fig. 8, a schematic of the electronic analogy is drawn.

The pressure sensors form the hydraulic capacities of the sensor. Due to the membrane deflection under a pressure load, liquid can be accumulated. In general, the hydraulic capacity $C_{\text{hyd}}$ is described by:

$$\phi = C_{\text{hyd}} \frac{d\rho}{dt}. \tag{17}$$

Since the flow rate is defined as the amount of transported volume per time, the capacitance is defined as the volume change per unit pressure variation:

$$C_{\text{hyd}} = \frac{dV}{d\rho}. \tag{18}$$

The volume under a square membrane is given by integrating the dimensionless deflection formula (4).

$$V = \int_{-Y}^{Y} \int_{-X}^{X} \frac{Q}{K_b} (1 - X^2)^2 (1 - Y^2)^2 \, dX \, dY = \frac{256}{225} \frac{Q}{K_b} \tag{19}$$

The capacity for the small deflections of a square membrane will be:

$$C_{\text{hyd}} = \frac{256}{225} \frac{a^6}{E h^3} \frac{1}{K_b} = 0.28 \frac{a^6}{E h^3} (1 - \nu^2). \tag{20}$$

It is assumed that both pressure sensors are identical such that the capacities at both sides of the resistance channel are identical.

Inertance of the sensor is caused by the acceleration of liquid mass in the sensor. Because the fluid velocity under the sensor membranes is assumed to be much smaller than the velocity in the hydraulic resistor, the kinetic energy is regarded to be concentrated in the resistor. Therefore, only the inertance in the resistor channel is taken into account. The hydraulic inertance, $L_{\text{hyd}}$, is defined by equation:

$$\Delta p = L_{\text{hyd}} \frac{d\phi}{dt}. \tag{21}$$

According to Newton’s second law, the force per area needed to accelerate a plug of liquid with length $l$ and cross-section area $S$ equals:

$$\Delta p = \rho l \frac{d\phi}{dt} \tag{22}$$

Hence the inerance of the filled channel with rectangular geometry (width $\times$ depth $= a \times b$) is defined by:

$$L_{\text{hyd}} = \frac{\rho l}{S} = \frac{\rho l}{a b} \tag{23}$$

The lumped element analogy of the electric circuit indicates that a second order system is to be expected. This electric equivalent circuit is shown in Fig. 8. The complex transfer function of a LRC circuit is expressed in Eq. (24).

$$G_{\text{hyd}} = \frac{1}{1 + j\omega R_{\text{hyd}} C_{\text{hyd}} - \omega^2 L_{\text{hyd}} C_{\text{hyd}}} \tag{24}$$

For this second-order system, resonance is to be expected for the LC combination at a frequency $f_{\text{hyd}}$ that satisfies Eq. (25) with a quality factor $Q_{\text{hyd}}$ expressed by Eq. (26).

$$f_{\text{hyd}} = \frac{1}{2\pi \sqrt{L_{\text{hyd}} C_{\text{hyd}}}} \tag{25}$$

$$Q_{\text{hyd}} = \frac{1}{R_{\text{hyd}} \sqrt{L_{\text{hyd}} C_{\text{hyd}}}} \tag{26}$$

The prototypes of the capacitive pressure/flow-sensor consist of square silicon membranes of about 25 $\mu$m thickness and a length and width of 1500 $\mu$m. The hydraulic capacity of these membranes will be around $1.7 \times 10^{-15}$ m$^3$/N. For the channels, three different widths are chosen: 200, 340 and 570 $\mu$m. The length is 2900 $\mu$m and the depth 21 $\mu$m. For the 340 $\mu$m wide channel, the resistance for ethanol becomes $1.7 \times 10^{12}$ Ns/m$^2$ with an inertance of $3/2 \times 10^6$ Ns$^2$/m$^3$. With these values, the resonance frequency is 2.2 kHz with quality factor 2.56. When the channel width is varied, the resistance and inertance will be affected. Figs. 9 and 10 show the computed amplitude and phase angle, respectively, of the transfer curves for the three different channel sizes.

From the equations, derived for the dynamic transfer of the sensor, it can be concluded that the current sensor design can be used dynamically with a fluid frequency up to about 1 kHz. If a higher dynamic range is wanted, the resonance frequency must be increased. If we look at Eq. (25), this is possible by reducing the hydraulic capacity or the inertance. The first parameter depends on the pressure sensor design. A reduction of the hydraulic capacity means that a more stiff membrane must be used which has consequences for the electric behavior: smaller gap sizes are needed between the upper and lower electrodes to gain
the same pressure sensitivity. When commercial dies are used for the pressure sensors, as for the piezo-resistive variant, the resistance channel can be varied, causing a change of the inertance but hydraulic resistance as well. Variation of the channel dimensions such that the resistance is kept within a pre-defined range, defined by the
sensitivity of the pressure sensors, and reducing the inertia can be the subject of optimization. A boundary condition in this is the length of the channel, which needs to be long enough to reduce the nonlinear effects of the entrance and exit resistance.

6. Accuracy and stability

Temperature changes can have strong influences on the stability of the sensor. The main influence of temperature variations on the sensor signal is due to a change of density and viscosity as temperature varies. For liquids, the absolute viscosity decreases with increasing temperature. This temperature dependent viscosity change [12] can be approximated for many liquids with the relation:

$$\frac{\mu(T)}{\mu_{293K}} = \exp \left( k_{\mu} \frac{293}{T} - 1 \right)$$

(27)

Temperature viscosity constants, \(k_{\mu}\), vary for different liquids. For ethanol for example this value is 5.72. At around 293 K, the relative change in viscosity will be about 2%/K. This influence of temperature on the viscosity will affect the sensor signal with the same amount because the viscosity is linearly related to the pressure drop as was shown by Eq. (11). This influence has consequences for the stability of the sensor. For high accuracy, the temperature of the liquid must be known or be controlled. For the first prototypes, no high precision was aimed at and thus no temperature regulation or sensing system was implemented. It can be concluded that for an uncompensated sensor, the sensor signal will give an underestimation of the ethanol volume flow rate of about 2%/K increase.

If we want to know the mass flow, the sensor volume flow signal must be multiplied with the mass density of the fluid. This density will vary with temperature according to [12]:

$$\frac{\rho(T)}{\rho_{293K}} = \frac{1}{1 + k_{\rho}(T - 293)}$$

(28)

Specific values for the volume expansion coefficient, \(k_{\rho}\), are around 110 \(\times\) 10\(^{-5}\)/K for ethanol, so that the change in mass density will be about 0.1%/K. If temperature rises, the density will decrease. The temperature induced density variation of ethanol will thus cause an underestimation of the mass flow rate of 0.1%/K temperature increase.

Besides the change in fluid properties, the geometry changes of the sensor also affect the hydraulic resistance. Since the resistance is inversely related to the channel cross-section with the fourth power, small variations in channel size will affect the resistance substantially and thus give deviations in measured pressure drops. The influence of the channel geometry can be expressed by the first derivative of the resistance to the geometry parameter. For simplicity, the situation of a circular channel is taken such that the resistance is inversely related to the fourth power of the diameter. The relative resistance change will thus be defined by:

$$\frac{1}{R_{hyd}} \frac{dR_{hyd}}{dd_{h}} = -\frac{4}{d_{h}}$$

(29)

The linear thermal expansion coefficient \(\alpha_T\) of the used glass (Hoya SD-2) is 3.2 \(\times\) 10\(^{-6}\) K\(^{-1}\). This means that the relative resistance change will be:

$$\frac{1}{R_{hyd}} \frac{dR_{hyd}(T)}{dT} = \frac{1}{R_{hyd}} \frac{\partial R_{hyd}}{\partial d_{hyd}} \frac{dd_{hyd}}{dT} = -4\alpha_T$$

(30)

Substituting \(\alpha_T\), gives a resistance change of only 1.28 \(\times\) 10\(^{-3}\)% . Hence the resistance change due to temperature induced geometry variations is negligible compared to the viscosity and density changes of the fluid. Other mechanisms such as pollution of the sensor, causing coverage of the channel walls can give rise to serious malfunctioning. Also, clogging up of the channel when particles are involved is disastrous.

7. Conclusions and discussion

A combination of a pressure and flow-sensor, based upon the principle of measuring the pressure drop over a hydraulic resistor, was discussed. The interesting aspect of this pressure/flow-sensor is that the principle is rather simple. It is comparable to measuring currents in an electrical circuit by sensing the voltage drop (= pressure drop) over a fixed resistance.

A few points make the sensor very suitable for micro fluid handling systems: Unlike many thermal mass flow-sensors [3], the electrical contacts of the pressure/flow-sensor are fully galvanic insulated from the fluid. There are no heater and sensor elements in electrical contact with the medium due to which a voltage drop may occur between the fluid and ground. For medicine dosing or some chemical analysis applications, this can be an important requirement. It also facilitates integration with other components, which lack galvanic insulation.

A second feature is the fact that no energy injection in the liquid is used. Only a little energy (\(\mu\)W) is extracted from the fluid stream due to friction. This means that heating up of the fluid is negligible which is an important issue for temperature sensitive materials or chemical reactions. The fact that there is only a little power consumed from the flow to obtain a pressure drop means that no additional electrical energy is needed to generate an actuator signal. These signals, like the heat transfer to the fluid in a thermal flow-sensor, usually consist of much energy.
Using a combination of capacitive pressure sensors further reduces the power consumption, which makes the sensor very suitable in low power applications.

The robustness of the sensor is rather high since there are no fragile bridges in the sensor, like the structures needed in many thermal flow-sensors. Membranes are the weakest structures used. They however are designed to withstand the maximum expected pressures and are no obstacle in the flow path. A final positive feature of the sensor is the reduction of the electronics needed for read-out. The electronics needed to read-out the pressure is also needed to measure the flow. So the same kind of electronics can be used or an additional multiplexer to read-out the second pressure sensor.

Besides these strong points, there are some weak points to consider. The mentioned positive aspect of a passive sensor also has a drawback. If the sensor is used in a system with for example micropumps to deliver flow at a certain pressure, these pumps must compensate the energy loss in the sensor due to friction. A good hydraulic resistance design, combined with sensitive pressure sensors can minimize this drawback.

With the principle of differential pressure flow sensing, the volume flow-rate instead of mass flow-rate is measured. For chemical analysis however, knowledge of mass flow is needed. Therefore, the mass density must be known in order to compute the mass flow. Another parameter that must be known to be able to derive the volume flow out of the pressure difference, is the viscosity. Changing the concentrations of the medium might affect both density as well as viscosity. These effects must be known in order to derive good volume flow values. Temperature changes of the fluid give rise to substantial fluctuations in viscosity. For ethanol at room temperature, this is 2% pressure change per Kelvin. Consequently fluid temperature measurements must be measured and/or controlled to reach a high flow measurement precision. On the longer term, the hydraulic resistance can change due to pollution. Therefore, like many thermal mass flow-sensors, the functionality is hampered when the walls get coated. Particles also form a severe threat because they can clog the resistance channel.

For the micromachined sensor design, presented in this paper, formulas are derived to predict the static as well as dynamic behavior. Because of the presence of hydraulic resistance, inerterance and capacitance, the device will act as a damped second order system with a resonance frequency in the range of a few kHz when ethanol is used as a fluid medium. Optimizing the hydraulic pressure sensor capacitance and channel geometry can increase this range.

These sensor aspects lead to the conclusion that the pressure/flow-sensor is simple and low power consuming dynamic fluid sensing device, capable of measuring both parameters, describing the hydraulic domain: pressure and flow-rate. If no temperature compensation is applied, the application area will be low precision flow rate measure-
ments. When temperature is known or controlled, high precision is possible.

References


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